



Cross section of a solder ball on a Ni / Cu pad prepared with the EM RES 101

## Leica EM RES 101

### Cross Section of a Solder Ball on a Cu/Ni Pad

**Market: Microelectronics QA/Research**

Companies (e.g.): AMD, ZMD, Infineon, Qimonda, STM, Intel, Tek, Bosch, Sony, Nokia, Sharp etc.

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# Leica EM RES 101 Application No. 1/7

## Cross Section of a Solder Ball on a Cu/Ni Pad

### Goal:

- Cross section of the solder ball structure to get information about the solder structure and its interface to the Cu / Ni pad

### Process description (benchmark values for this particular sample):

Parameter	
Acceleration voltage	7 kV
Gun current	2.6 mA
Sample movement	Oscillation
Milling time	6 h 30 min

### Results:

- Cross section of the solder ball structure without any damages
- The grain structure of the different materials is clearly visible
- Interfaces can be investigated

Wolfgang Grünewald, Leica Microsystems

Wolfgang.Gruenewald@leica-microsystems.com